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(12) **United States Design Patent**
Nakamura et al.

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- (54) **COSMETIC MASK**
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- (**) Term: **15 Years**
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- (30) **Foreign Application Priority Data**
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- (51) **LOC (13) Cl.** **28-03**
- (52) **U.S. Cl.**
USPC **D28/7**
- (58) **Field of Classification Search**
USPC D28/7, 8, 99; D29/108; D21/660
CPC A45D 44/002; A45D 2200/1009
See application file for complete search history.

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(57) **CLAIM**

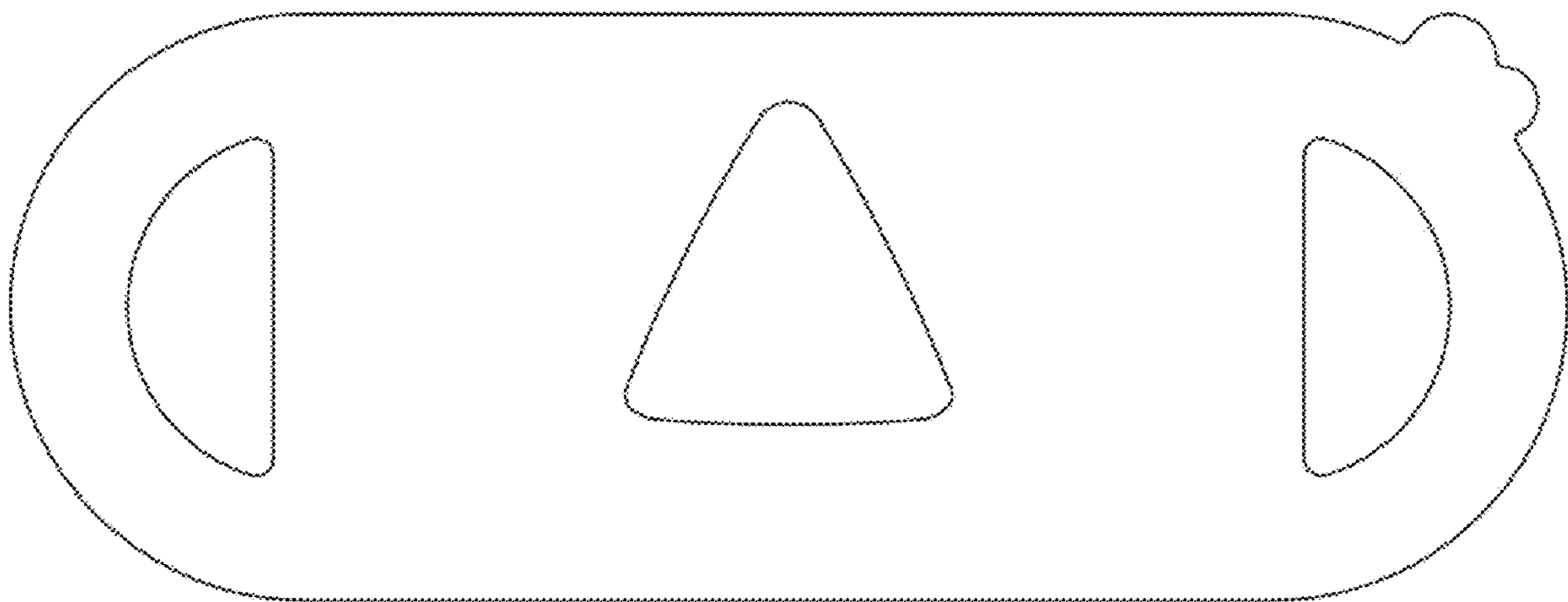
The ornamental design for a cosmetic mask, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a cosmetic mask showing our new design;
FIG. 2 is a front view thereof, the rear view being a mirror image thereof;
FIG. 3 is a left side view thereof;
FIG. 4 is a right side view thereof;
FIG. 5 is a top view thereof; and,
FIG. 6 is a bottom view thereof.

1 Claim, 2 Drawing Sheets

- (56) **References Cited**
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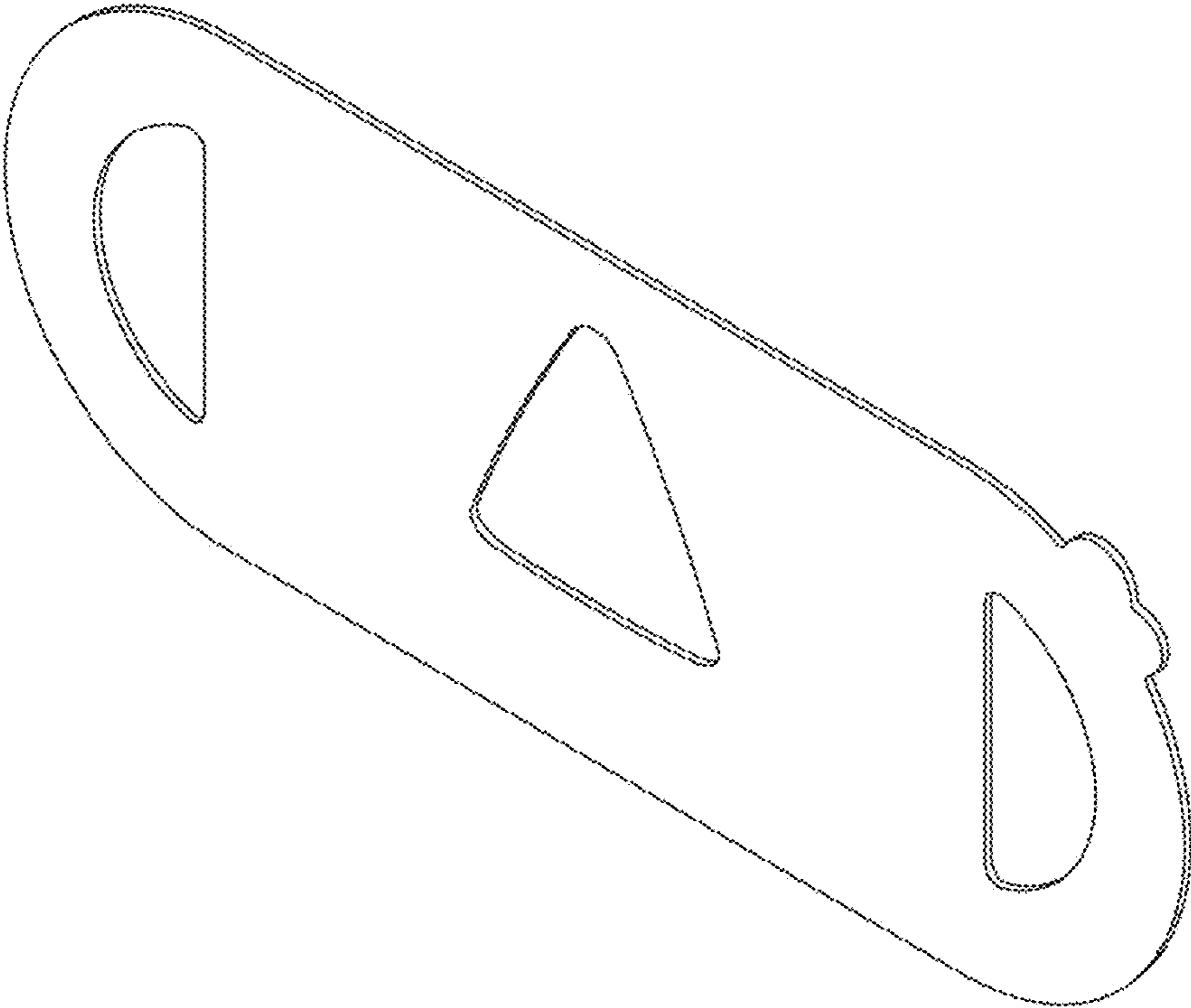


FIG. 1

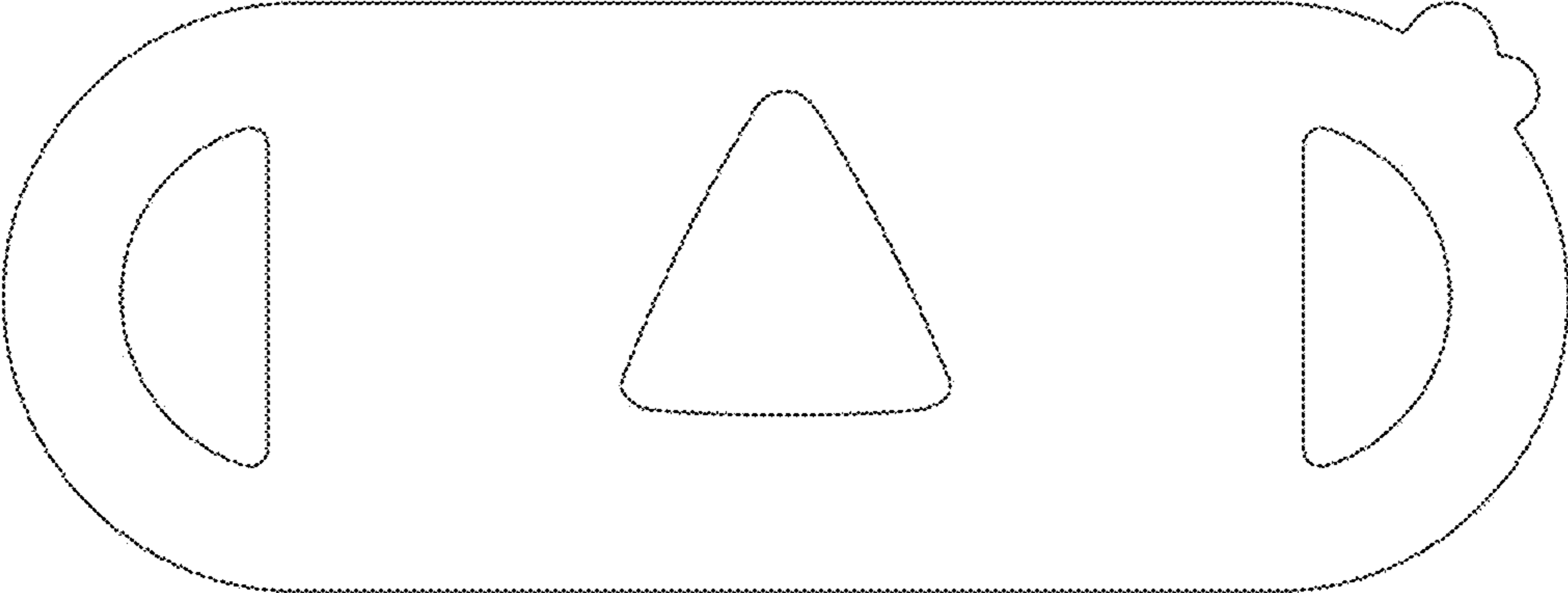


FIG. 2



FIG. 3



FIG. 4



FIG. 5



FIG. 6